



NEO

CHEMICAL DOSING PUMP



APPLICATION

The TAFLO Edose is a constant flow chemical dosing pump suitable for a wide range of chemicals for water treatment and industrial dosing systems

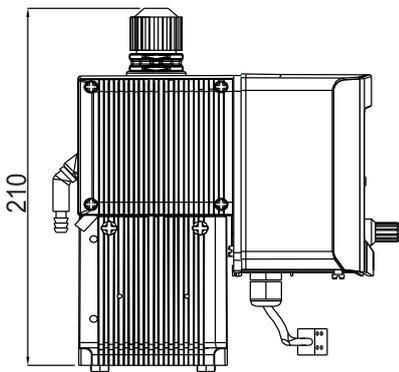
CONSTRUCTION FEATURES

- User friendly knob linked with digital display for adjusting dosing frequency
- Dosing head conveniently located next to front controls for easy maintenance access
- Built-in ARV with separate discharge point to prevent chemical spillage on hands
- Diaphragm made of solid PTFE to ensure maximum life
- Batch and interval dosing features
- Double ball NRV
- Level switch interlock
- 4 to 20 mA input
- Pulse input
- Relay output
- Backlight LCD display
- IP65

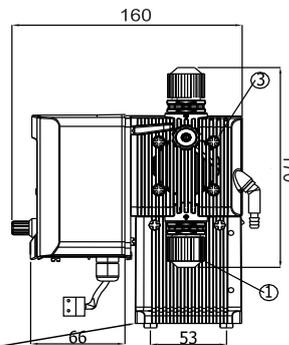
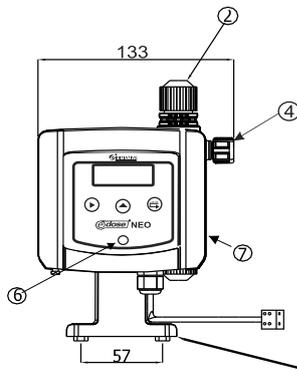
Scope of supply

The pumps are supplied with the following accessories

- Suction/Discharge tubing
- Suction filter with NRV
- Mounting bolts
- O & M manual



- 5. MOUNTING BRACKET
- 6. FREQUENCY ADJUSTMENT KNOB
- 7. PCB HOUSING



- 1. SUCTION VALVE
- 2. DISCHARGE VALVE
- 3. DOSING HEAD
- 4. AIR RELEASE VALVE

TECHNICAL DATA

Dosing rate @ 4kg/cm ³	1.5, 3, 6, & 10 lph
Suction/Discharge tubing	4/6 mm
Frequency	upto 400spm
Electrical	230V AC, 50Hz
Power consumption at 400 spm	30watts